

# 6.772 – Compound Semiconductors

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## **Auger recombination in $A^{III}B^V$ compound semiconductors: non-radiative losses in quantum wells and superlattices**

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# Outline

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- ❖ Carrier recombination mechanisms in semiconductors
    - ✓ non-radiative channel: Auger recombination
    - ✓ source of dark current in lasers and detectors
    - ✓ optimized laser structure to reduce Auger
  - ❖ Auger recombination enhancement in heterostructures
    - ✓ narrow-gap semiconductor
    - ✓ high doping level
    - ✓ high injection level
    - ✓ wavefunction localization
    - ✓ breaking momentum conservation
  - ❖ Theoretical model for direct-gap  $A^{III}B^V$  semiconductors
  - ❖ Experimental measurements of lifetime for Auger process
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# Carrier Recombination in Semiconductors

## ❖ Radiative recombination

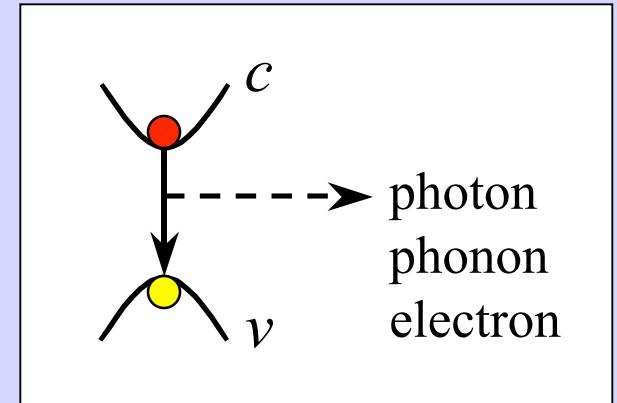
recombination rate:  $R_{\text{rad}} = B(T) n p$

n-type  $\square$  lifetime:  $\tau_{\text{rad}} = (B(T) n_0)^{1/2}$

$$R_{\text{rad}} = p / \tau_{\text{rad}}$$

direct bandgap: photon  $h\nu \ll E_g$

indirect bandgap: photon  $h\nu \ll E_g + \text{phonon } h\nu \ll E_g$



## ❖ Non-Radiative recombination

✓ phonon:  $h\nu \ll E_g \square$  trap-assisted (middle-gap, Shockley-Read-Hall)

rate:  $R_{\text{trap}} = A(T) p = p / \tau_{\text{trap}}$  where  $\tau_{\text{trap}} = A(T)^{1/2}$

✓ electron: Auger recombination

rate:  $R_{\text{Auger}} = C(T) n^2 p = p / \tau_{\text{Auger}}$  where  $\tau_{\text{Auger}} = (C(T) n_0^2)^{1/2}$

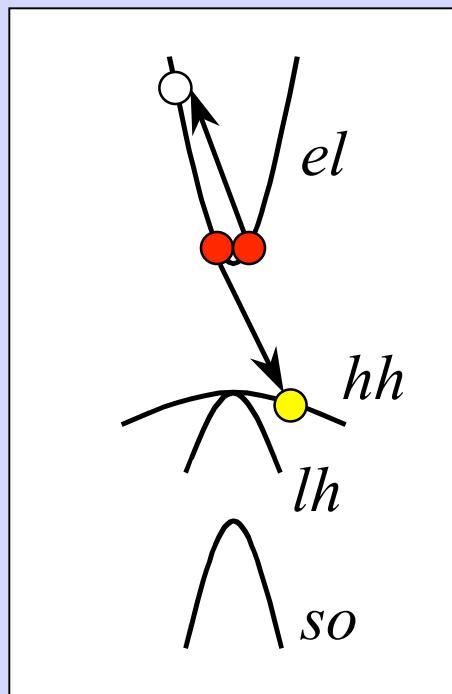
# Auger Recombination in Semiconductors

$$\square_{\text{trap}} \square^1 = A \ll \square_{\text{Auger}} \square^1 = C n_0^2 \ll \square_{\text{rad}} \square^1 = B n_0$$

high doping level  $\square$  dominant: radiative + Auger

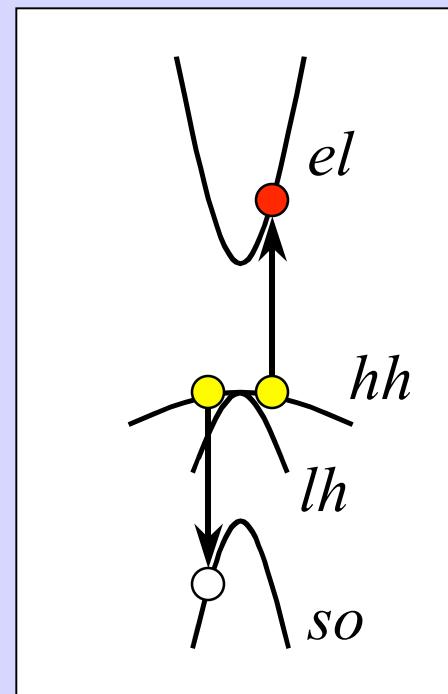
CHCC  
Auger  
process

energy is transferred to an electron  
direct processes



CHHS  
Auger  
process

energy is transferred to a hole  
enhancement  
 $E_g = \square_{\text{SO}}$



momentum conservation  $\square$  temperature threshold  $\square$  photon-assisted

# Auger Recombination in Heterostructures

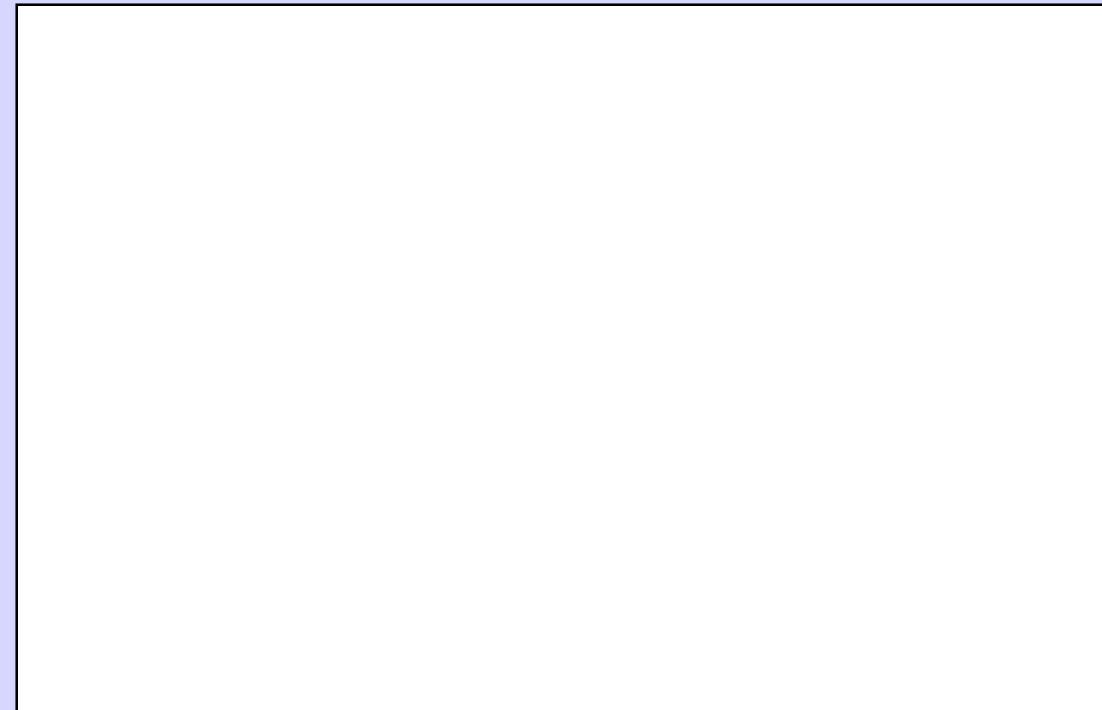
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- wavefunction localization within the quantum well
- enhancement of coefficients A( $\uparrow$ ), B( $\uparrow\uparrow$ ), C( $\uparrow\uparrow\uparrow$ )

direct Auger process

- 1) CHCC
- 2) CHHS

phonon-assisted  
higher-order  
impurity scattering  
*etc*

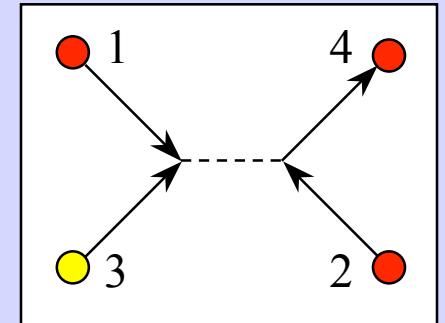
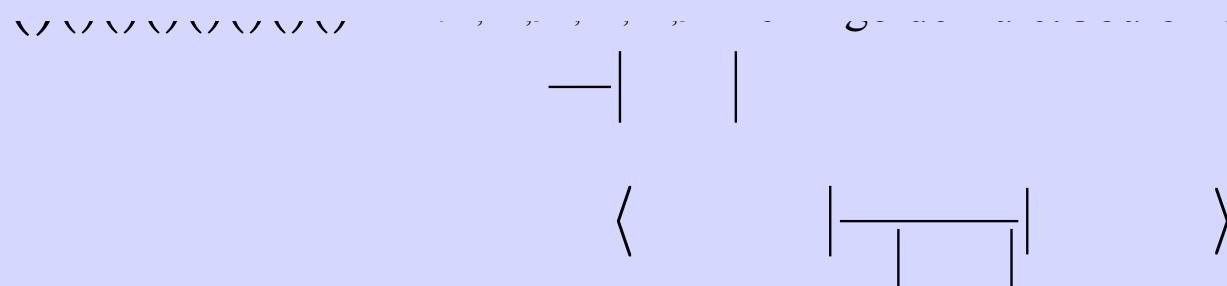


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<http://www.ioffe.rssi.ru/SVA/NSM/Auger/model.html>

[http://www.wsi.tu-muenchen.de/nextnano3/input\\_parser/database/Auger-recombination.htm](http://www.wsi.tu-muenchen.de/nextnano3/input_parser/database/Auger-recombination.htm)

# Direct Auger Recombination Mechanism

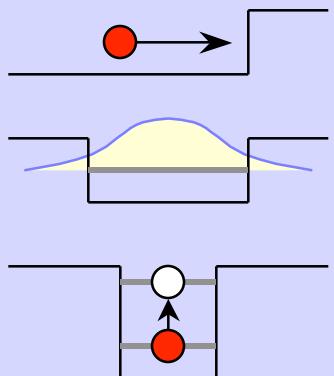


Auger coefficient in heterostructures:  $C = C_1 + C_2 + C_3$

$C_1$ : electronic scattering on a single heterobarrier

$C_2$ : Coulomb interaction within the quantum well

$C_3$ : Auger electron in the bound state (deep QW)



quantum well   □   momentum non-conservation   □   thresholdless

A. S. Polkovnikov and G. G. Zegrya, Phys. Rev. B 64, 073205 (2001)  
*ibid*, Phys. Rev. B 58, 4039 (1998)

# Direct Auger Recombination Calculation

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Auger coefficients ( $C_1, C_2, C_3$ ) different origin □  
different dependencies on QW width, temperature, bandgap, barriers  
(temperature thresholdless □ breaking momentum conservation)

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A. S. Polkovnikov and G. G. Zegrya, Phys. Rev. B 64, 073205 (2001)  
*ibid*, Phys. Rev. B 58, 4039 (1998)

# Phonon-Assisted Auger Recombination

Theoretical calculation for n-type  
InGaAsP lattice matched to InP

$$\square_{\text{Auger}} = (Cn^2)^{\square 1}$$

Auger recombination processes:  
narrow-gap : direct (dominant)  
wide-gap : phonon-assisted

Auger theory: the sensitivity of  
the calculation to the band model,  
wavefunctions, and other  
approximations used

$\square$  disagreements...

**N. K. Dutta and R. J. Nelson, J. Appl. Phys. 54, 74 (1982)**  
**M. Takeshima, Phys. Rev. B 23, 6625 (1981)**

# Recombination Lifetime in narrow-gap InGaAs

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$$\tau = [A + B n + C n^2]^{-1}$$

$\left\{ \begin{array}{ll} A & \text{— trap-assisted} & [\text{phonon}] \\ B & \text{— radiative} & [\text{photon}] \\ C & \text{— Auger} & [\text{electron}] \end{array} \right.$

n-type

$\text{In}_x\text{Ga}_{1-x}\text{As}$   
 $0.53 < x < 1$

$$\tau \propto n^{-x}$$

direct:

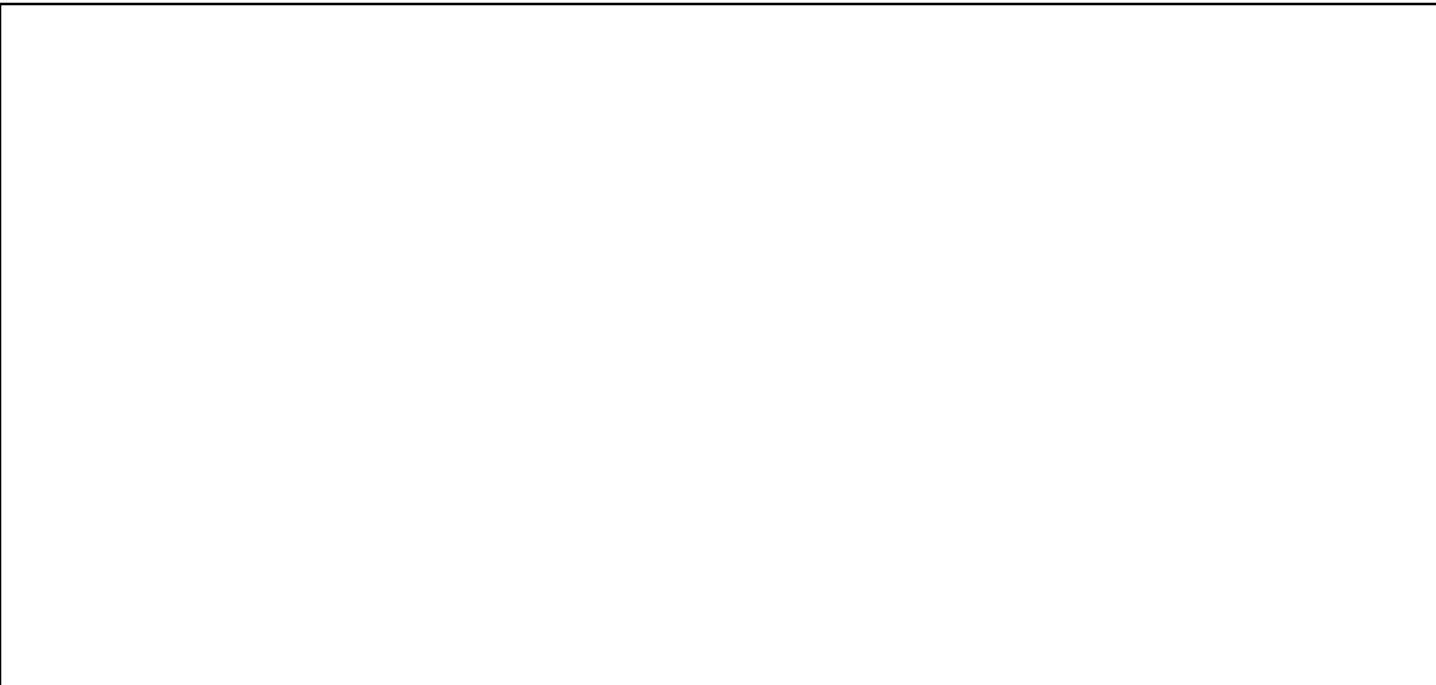
$$x = 1$$

phon-assist:

$$x = 2$$

second-order:

$$x = 7/3$$



# Auger lifetime in GaInAsSb/GaSb compounds

Auger coefficient increases with decreasing band-gap

Auger coefficient increases when  $E_g = \Delta_{SO}$  (CHHS process) as observed experimentally

**M. Muñoz, K. Wei, F. H. Pollak,  
J. L. Freeouf, C. A. Wang, and  
C. W. Charache, J. Appl. Phys.  
87, 1780 (2000)**

Carrier lifetime is measured by the standard small-signal optical response technique

**J. M. Pikal, C. S. Menoni, H. Temkin,  
P. Thiagarajan, G. Y. Robinson,  
Rev. Sci. Instrum. 69, 4247 (1998)**

**I. Riech, M. L. Gomez-Herrera, P. Díaz, J. G. Mendoza-Alvarez, J. L. Herrera-Pérez, E. Marín,  
Appl. Phys. Lett. 79, 964 (2001) and references therein**

# Temperature Dependence of Recombination

InAsP/InGaAsP multiple QW laser  
with band-gap wavelengths

- 1.15  $\mu\text{m}$  (shallow gap)
- 1.06  $\mu\text{m}$  (deep gap)

$$\square = [ A + B n + C n^2 ]^{\square 1}$$

Nearly 50% of threshold current is  
due to Auger at room temperature

## enhancement

Analysis	Shallow well		Deep well	
	Bulk	QW	Bulk	QW
$A \times 10^{-7}$	3.3	4.5	3.5	3.5
$B \times 10^{11}$	3.1	x100	7.2	4.9
$C \times 10^{29}$	.058	→	5.1	1.0

J. M. Pikal, C. S. Menoni, P. Thiagarajan, G. Y. Robinson, and H. Temkin,  
Appl. Phys. Lett. 76, 2659 (2000)

# Narrow-gap InAs/GaSb/AlSb Superlattices

$$R = A + B n + C n^2$$

Experimental (solid diamonds) and computed (hollow squares) total recombination rates per electron-hole pair for the four systems. The dashed lines are fits of the experimental data to the equation shown above.

optimal lasing density for structures (a)–(c) is close to  $10^{18} \text{ cm}^{-3}$  and  $C n^2 > 10 \text{ A}$  for these densities

the structure (d) is optimized for Auger suppression (sensitive to layer thicknesses □ errors in growth & band model)

**C. H. Grein, M. E. Flatté, J. T. Olesberg, S. A. Anson, L. Zhang, T. F. Boggess,  
J. Appl. Phys. 92, 7311 (2002)**

# Summary

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- ❖ Theoretical modeling of Auger recombination
    - ✓ contradictory results from different groups
    - ✓ very sensitive to band structure models
  - ❖ Experimental measurements of Auger coefficient
    - ✓ confirms many theoretical predictions
    - ✓ increase in QWs of narrow-gap materials
  - ❖ Optimize long-wavelength lasers and detectors to minimize Auger recombination (reduce threshold and dark current)
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